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**- Supplementary Information -**

# Liquid thin film dewetting-driven micropatterning of reduced graphene oxide electrodes for high performance OFETs

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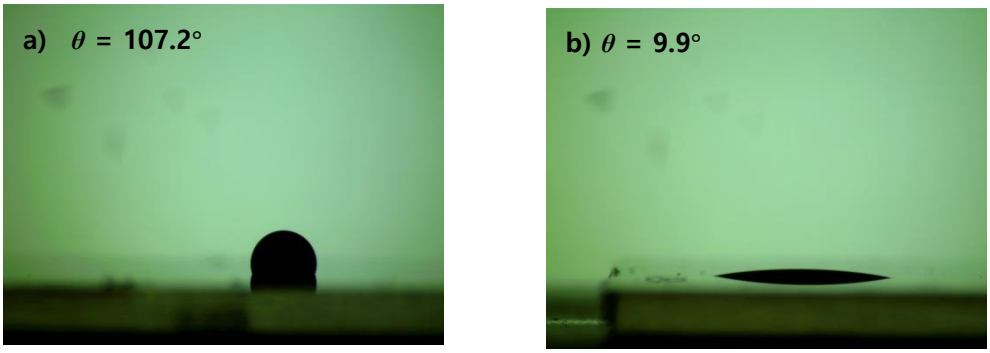


**Figure S1.** Contact angle ($\theta$) of 6.65 mg/mL GO solution on (a) ODTS-treated substrate and (b) UV-$O_3$ treated substrate.

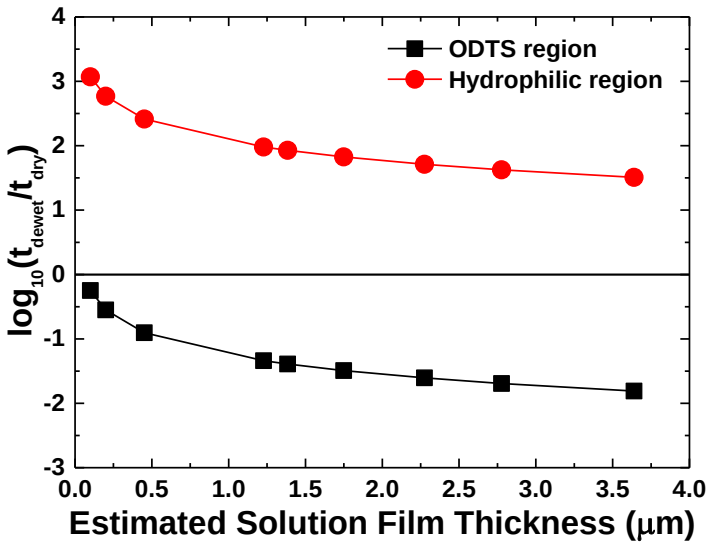


**Figure S2.** Relative time scale of dewetting and drying times ($t_{dewet}/t_{dry}$) on hydrophilic and ODTS-treated regions as a function of the liquid thin film thickness estimated by equation (1).

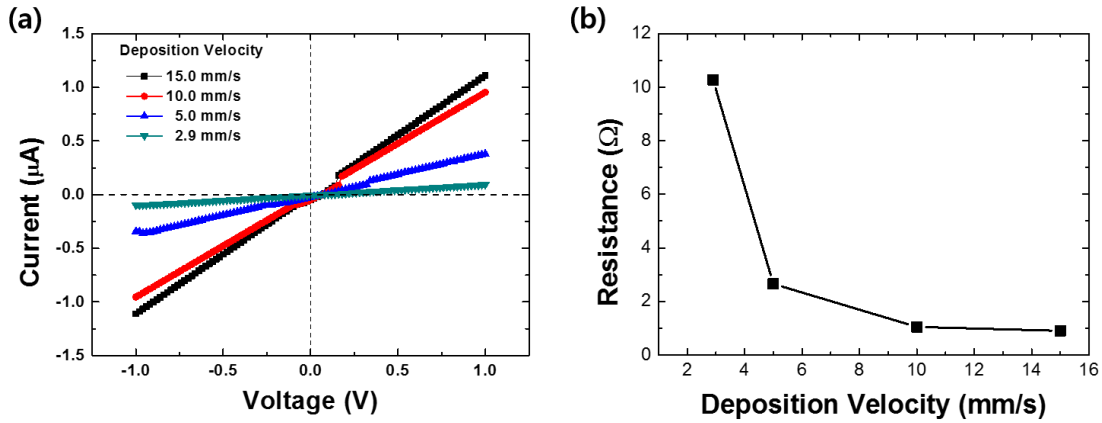


**Figure S3.** (a) I-V characteristic plot and (b) corresponding resistance profile of the rGO line patterns prepared with different deposition velocities in Figure 3b.